

Mark Name	TM Application Status	Country
300WORKS	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
		United Kingdom
		United States of America
		A (stylized)
		Benelux
		Brazil
		Canada
		China
		European Union
		France
		Germany (Federal Republic of)
		Hong Kong
		India
		Indonesia
		International
		Ireland (Republic of)
		Israel
		Italy
		Japan
		Korea, Republic of (KR)
		Malaysia
		Mexico
		Philippines
		Russian Federation
		Singapore
		Spain
		Sweden
		Switzerland

A (stylized)	Registered	Taiwan Thailand United Arab Emirates United Kingdom United States of America
A (stylized) (with Cropped Banner Device)	Registered	China
A APPLIED MATERIALS (stylized in centered presentation)	Registered	China
A APPLIED MATERIALS (stylized)	Registered	China Thailand United States of America
A APPLIED MATERIALS MAKE POSSIBLE (stylized)	Registered	Taiwan
ACCESS	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
ACENTA	Allowed Application Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
ACTIVITY MANAGER	Application Registered	China International Japan Korea, Republic of (KR) United States of America
Acuity	Registered	China European Union International Japan

Acuity	Registered	Singapore United States of America
ADEN	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
ADVENT	Registered	Taiwan
AdvisorMV	Registered	European Union United Kingdom
AERA	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore United States of America
AERIS	Application Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AF-Mag	Registered	Benelux China Czechia Finland France Hungary International Italy Japan Korea, Republic of (KR) Liechtenstein Poland Portugal Spain

AF-Mag	Registered	Sweden Switzerland Taiwan Turkey United Kingdom
Agile ALD	Application	China
	Registered	India Canada European Union International Japan Korea, Republic of (KR) Russian Federation Singapore Switzerland Taiwan United Kingdom United States of America
AI Design Forum	Registered	United States of America
AI OLED	Application	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
AI(X)	Allowed	United States of America
	Application	China
	Registered	European Union International Israel Japan Singapore Taiwan
AIDF	Registered	United States of America
AITHION	Registered	Australia Canada

AITHION

Registered

China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United Kingdom
United States of America

AIX

**Allowed
Application
Registered**

United States of America
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Taiwan

AJAX

Registered

China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

AKT

**Application
Registered**

China
International
China
Germany (Federal Republic of)
Ireland (Republic of)
Japan
Korea, Republic of (KR)
Taiwan
United Kingdom

AKT	Registered	United States of America
AKTIV	Application	China
ALPS	Registered	United States of America
ALTA	Registered	United States of America France Germany (Federal Republic of) United States of America
Alteza	Allowed	Taiwan
	Application	United States of America European Union Japan Korea, Republic of (KR)
	Published	Israel Singapore
	Registered	China
ALTUM	Registered	International Australia Canada China European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom United States of America
AMAT	Registered	Benelux
APF	Registered	United States of America
APF FUSION	Registered	United States of America
APF RTD	Registered	China European Union International Japan Korea, Republic of (KR)

APF RTD	Registered	Singapore Taiwan United Kingdom United States of America
APOLLO	Allowed Published Registered	Taiwan Korea, Republic of (KR) Japan United States of America
APPLIED	Registered	Benelux Japan China
APPLIED AERIS	Registered	China
APPLIED AERIS-G	Published	China
Applied AI(X)	Registered	China
Applied AI(X)	Allowed	United States of America
APPLIED CHARGER	Registered	United States of America
APPLIED E3	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
APPLIED ENDURA IMPULSE	Application	China International Japan Korea, Republic of (KR) Taiwan United States of America
APPLIED FABVANTAGE	Registered	Japan Korea, Republic of (KR) Taiwan United States of America
Applied Forecast Parts Management	Registered	International Japan Korea, Republic of (KR) Taiwan

Applied Forecast Parts Management	Registered	United States of America
APPLIED GLOBAL SERVICES	Registered	United States of America
Applied Inside OLED	Application	European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
Applied Managed Service	Registered Registered	International International Japan Taiwan United States of America
APPLIED MATERIALS	Registered	Australia Benelux Brazil Canada China European Union France Germany (Federal Republic of) Hong Kong India Indonesia International Ireland (Republic of) Israel Italy Japan Korea, Republic of (KR) Malaysia Mexico Philippines Russian Federation Singapore Spain Sweden Switzerland

APPLIED MATERIALS	Registered	Taiwan United Arab Emirates United Kingdom United States of America
APPLIED MATERIALS A (stylized) (with Blue Banner Device)	Registered	China
APPLIED MATERIALS A (stylized) and Chinese Characters	Registered	China
APPLIED MATERIALS A (stylized) and Chinese Characters (with Rounded Rectangle Device)	Registered	China
APPLIED MATERIALS and Japanese Characters	Registered	Japan
Applied Materials DLT	Application	United States of America
APPLIED MATERIALS, INC	Registered	China
APPLIED MOSAIC	Application	United States of America
Applied Nanophotonics	Application	Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
APPLIED OLYMPIA	Registered	International
APPLIED OLYMPIA ALD	Registered	Japan
Applied OnDemand	Application	Japan
	Registered	China International Japan Taiwan
APPLIED OPUS	Registered	United States of America
APPLIED PERFORMANCE SERVICE	Registered	United States of America International Japan Korea, Republic of (KR) Taiwan
APPLIED SANSA	Registered	United States of America
APPLIED SMARTFACTORY	Registered	China European Union International Japan Singapore Taiwan United Kingdom

APPLIED SMARTFACTORY	Registered	United States of America
APPLIED SMARTFACTORY RX	Registered	China Taiwan
APPLIED SPRINTER	Registered	China
APPLIED THERMION	Registered	Japan Taiwan
APPLIED VENTURES	Registered	United States of America
appliedmaterials.tw	Registered	Taiwan
AppliedPRO	Application	Japan Korea, Republic of (KR) Malaysia Singapore
	Registered	Canada European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan
AppliedTwin	Application	United States of America China Korea, Republic of (KR)
	Published	United States of America
	Registered	European Union International Japan Singapore Taiwan
ARAGON	Allowed	United States of America
	Registered	China International Japan Korea, Republic of (KR) Singapore Taiwan

arCADE	Allowed Application	United States of America China Israel Japan Korea, Republic of (KR) Taiwan
ArchitectMV	Registered Application	European Union International Singapore United Kingdom
Arian	Registered	Korea, Republic of (KR) International
ARISTO	Registered	Germany (Federal Republic of)
ARNO	Allowed Registered	United States of America China International Japan Korea, Republic of (KR) Singapore Taiwan
AthenaAI	Registered	European Union International Israel Japan Singapore United States of America
AUTOMOD	Published Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom
AUTOSCHED	Registered	United States of America China European Union International Japan

AUTOSCHED	Registered	Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
AVATAR	Registered	China United States of America
AVENIR	Registered	United States of America
AVILA	Registered	United States of America
AVINA	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
AVOR	Application	China European Union Japan Korea, Republic of (KR) Singapore Taiwan United States of America
AXCELA	Registered Application	International International Japan Korea, Republic of (KR) Malaysia Taiwan United States of America
AXIOM	Published	United States of America
B (stylized)	Registered	China European Union Singapore United States of America Australia Belarus China

B (stylized)

Registered

Croatia
European Union
Hong Kong
India
International
Italy
Japan
Korea, Republic of (KR)
Liechtenstein
Norway
Russian Federation
Serbia
Singapore
Switzerland
Taiwan
Turkey
Ukraine
United Kingdom
United States of America

BACCINI (stylized)

Registered

Vietnam
Australia
Belarus
China
Croatia
European Union
Hong Kong
India
International
Italy
Japan
Korea, Republic of (KR)
Liechtenstein
Norway
Russian Federation
Serbia
Singapore
Switzerland
Taiwan

BACCINI (stylized)	Registered	Turkey Ukraine United Kingdom United States of America Vietnam
BatchMV	Registered	United Kingdom
BioAPC	Allowed	United States of America
	Registered	Singapore United Kingdom
BioMV	Registered	United Kingdom
BIONEURON	Registered	United Kingdom
BLACK DIAMOND	Registered	Japan United States of America
BLACKHAWK	Registered	China Korea, Republic of (KR) Taiwan United States of America
BLACKSTONE	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
CARINA	Registered	United States of America
CATALYST	Allowed	United States of America
	Application	China Japan
	Published	Singapore
	Registered	European Union International Korea, Republic of (KR)
CELLWORKS	Registered	Singapore United Kingdom United States of America
CENTINEL	Registered	United States of America
CENTRIS	Registered	China United States of America
CENTURA	Registered	Benelux

CENTURA

Registered

China
European Union
France
Germany (Federal Republic of)
Hong Kong
India
Indonesia
Ireland (Republic of)
Israel
Italy
Japan
Korea, Republic of (KR)
Singapore
Spain
Sweden
Switzerland
Taiwan
United Kingdom
United States of America

CENTURA (and Katakana version)

Registered

CENTURA WXP

Registered

Japan
Singapore
Taiwan

ChamberAI

Application

Registered

China
Canada
European Union
International
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan

ChamberTwin

Application

Published

Registered

United States of America
China
Japan
Korea, Republic of (KR)
United States of America
European Union

ChamberTwin	Registered	International Singapore Taiwan
Ciena	Registered	United States of America
CLARA	Application	China Korea, Republic of (KR)
CLARION	Registered Registered	International China European Union International Korea, Republic of (KR) Singapore Taiwan United States of America
CLARIPHI	Allowed Registered	Japan China Korea, Republic of (KR) Taiwan United States of America
CLASS MCS 5	Application Registered	Malaysia China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
CLEAN MODE	Registered	United Kingdom
CLEANCOAT	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
CLERE	Allowed Registered	United States of America Canada China European Union

CLERE	Registered	International Israel Japan Korea, Republic of (KR) Malaysia Singapore Taiwan
CloudSim	Allowed Application	United States of America Japan Korea, Republic of (KR)
	Registered	European Union International Singapore Taiwan
CLOVER	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
ComPLUS	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
CONFORMA	Registered	International Taiwan
Contorno	Registered Application Published Registered	Korea, Republic of (KR) United States of America China European Union International Israel

Contorno	Registered	Japan Singapore Taiwan
Contour	Allowed	United States of America
ControlMV	Registered	United Kingdom
CORNERSTONE	Registered	United Kingdom
CORONA UV	Registered	Korea, Republic of (KR) Taiwan
CORSA	Application Registered	International Australia Canada China European Union Israel Japan Korea, Republic of (KR) Singapore Switzerland Taiwan United Kingdom United States of America
CRION	Registered	United States of America
CrossMatch	Registered	United States of America
Cupryx	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
DARC	Registered	Korea, Republic of (KR) Taiwan United States of America
DESICA	Registered	United States of America
DeviceTwin	Application	United States of America Korea, Republic of (KR) Singapore United States of America

DeviceTwin	Registered	International Japan
Digital Dynamic Connection	Application Registered	United States of America European Union International Japan Korea, Republic of (KR) Singapore
DIMENSION	Registered	China France Germany (Federal Republic of) International Israel Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
DLT	Application	China European Union Israel Japan Korea, Republic of (KR) Singapore United States of America
DMO SYSTEMS	Registered	International
DPS	Registered	Taiwan China European Union Korea, Republic of (KR) Singapore United Kingdom United States of America
DPS CENTURA	Registered	Benelux France Germany (Federal Republic of) Hong Kong

DPS CENTURA

Registered

Indonesia
Ireland (Republic of)
Italy
Japan
Korea, Republic of (KR)
Singapore
Spain
Sweden
Taiwan
United Kingdom
United States of America

DRACO

Registered

China
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United States of America

DROSSA

Registered

China
International
Japan
Korea, Republic of (KR)
Taiwan

DSF

**Allowed
Registered**

United States of America
China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan

DSFm

**Allowed
Application**

Taiwan
United States of America
China
European Union
Japan
Korea, Republic of (KR)
Singapore

DSFm	Registered	International
DURASOURCE	Registered	United States of America
DURUM	Registered	China European Union International Japan Korea, Republic of (KR) Malaysia Singapore Taiwan
EBT	Application	United States of America China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan
EcoTwin	Registered Registered	United States of America International European Union International Japan Korea, Republic of (KR) Singapore Taiwan
ecoUP	Application	United States of America China European Union Israel Japan Korea, Republic of (KR) Singapore Taiwan
	Published	United States of America United Kingdom
	Registered	United States of America European Union

<p>ecoUP EduTwin</p>	<p>Registered Allowed Application Registered</p>	<p>International United States of America Korea, Republic of (KR) European Union International Israel Japan Singapore Taiwan</p>
<p>Elevated Materials</p>	<p>Allowed Application Registered</p>	<p>United States of America Korea, Republic of (KR) China European Union International Japan Taiwan</p>
<p>Eli</p>	<p>Allowed Application Registered</p>	<p>United States of America China Korea, Republic of (KR) European Union International Japan Singapore Taiwan</p>
<p>ELLUMINATOR</p>	<p>Application Registered</p>	<p>China Korea, Republic of (KR) Taiwan European Union International Japan United Kingdom</p>
<p>EMAX ENDURA</p>	<p>Registered Registered</p>	<p>United States of America United States of America Benelux China European Union France Germany (Federal Republic of)</p>

ENDURA

Registered

Hong Kong
India
Indonesia
Ireland (Republic of)
Israel
Italy
Japan
Korea, Republic of (KR)
Singapore
Spain
Sweden
Switzerland
Taiwan
United Kingdom
United States of America

ENDURA CIRRUS

Registered

China
European Union
International
Japan
Korea, Republic of (KR)
Singapore
Taiwan

ENDURA IMPULSE

**Allowed
Registered**

United States of America
United States of America
China

ENFLEXOR

Registered

United States of America

ENGINEEREDWORKS

**Application
Registered**

International
European Union
Japan
Korea, Republic of (KR)
Singapore
Taiwan
United Kingdom
United States of America
Korea, Republic of (KR)
United States of America
European Union
International

EngineeringTwin

**Application
Published
Registered**

EngineeringTwin	Registered	Japan Singapore
ENLIGHT	Application	China Korea, Republic of (KR) Taiwan
	Registered	European Union Israel Japan Singapore
ENZO	Allowed	United States of America United States of America
	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
Eona	Application	United States of America
EPIC	Application	China Japan Korea, Republic of (KR) Singapore Taiwan United States of America
	Registered	European Union International Taiwan
Epic Center	Allowed	United States of America
	Application	China European Union Japan Korea, Republic of (KR) Taiwan
	Published	Singapore
	Registered	International
ESATTO AOI	Registered	China Taiwan

ESATTO HP kit	Registered	China Taiwan
ESATTO HP+	Registered	China Taiwan
ESATTO SEm	Registered	China Taiwan
ESATTO TECHNOLOGY	Registered	China Korea, Republic of (KR) United States of America
ESCOSYS	Registered	Austria Benelux China France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Switzerland United Kingdom
ETERNA	Application	Korea, Republic of (KR) Taiwan
	Registered	China United States of America
ETERNA FCVD	Registered	Taiwan United States of America
ETERNA TRINITY	Registered	United States of America
EXECTA	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
EXPRESS EXCHANGE	Registered	United States of America
ExtractAI	Allowed Application	United States of America Israel Japan Korea, Republic of (KR)

ExtractAI	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore
EYED	Registered	United States of America
FAB300	Registered	Australia Benelux France Germany (Federal Republic of) Israel United States of America
FabOptimizer	Registered	United States of America
FACTORYWORKS	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
FCVD	Registered	China International Japan Korea, Republic of (KR) Malaysia Taiwan United States of America
FERMI	Registered	International Japan Korea, Republic of (KR) Taiwan
FINE LINE DOUBLE PRINTING	Registered	United States of America
FLDP	Registered	United States of America United States of America

FleetTwin	Application	China Korea, Republic of (KR) United States of America
	Registered	European Union International Japan Singapore Taiwan
Forma	Allowed Application	United States of America China Korea, Republic of (KR)
	Published Registered	Israel European Union International Japan Singapore Taiwan
FormulateAPC	Registered	United Kingdom
FormulateMV	Registered	United Kingdom
Fortis	Allowed Application	United States of America China Japan
	Registered	European Union International Korea, Republic of (KR) Singapore Taiwan
Forza	Application	China European Union Japan Korea, Republic of (KR) Taiwan
	Published Registered	United States of America Singapore International
FULLVISION	Registered	United States of America
GARNET	Allowed Registered	United States of America Korea, Republic of (KR)

GEBI

Registered

Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore
Switzerland
United Kingdom
United States of America

GINESTRA

Registered

Canada
China
European Union
International
Israel
Japan
Korea, Republic of (KR)
Malaysia
Singapore
Switzerland
Taiwan
United Kingdom
United States of America

GUARDIAN

Registered

United States of America

HARP

Registered

China
International
Japan
Korea, Republic of (KR)
Taiwan

HawkEye

**Allowed
Registered**

United States of America
United States of America
European Union
International
Israel
Japan
Korea, Republic of (KR)
Singapore

HawkEye	Registered	Taiwan
HEADSMART	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Malaysia
		Singapore
		Taiwan
		United Kingdom
		United States of America
HIRES	Registered	China
		Germany (Federal Republic of)
		India
		International
		Italy
		Japan
		Korea, Republic of (KR)
		United States of America
HydroClean	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
		United Kingdom
		United States of America
HydroCoat	Registered	European Union
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
		United Kingdom
		United States of America
HyperSense	Allowed Application	United States of America
	Registered	Israel
		European Union
		International

HyperSense	Registered	Japan Korea, Republic of (KR) Singapore Taiwan
IC^N	Application	United States of America
ICT	Registered	Germany (Federal Republic of)
ICT (and Design)	Registered	Germany (Federal Republic of) United Kingdom United States of America
IMAP	Registered	United States of America
IMPULSE	Registered	China European Union Korea, Republic of (KR) Taiwan United Kingdom
IMS	Application	China Israel Japan Taiwan
	Registered	United States of America European Union International Korea, Republic of (KR) Singapore
Indigo	Application	China Japan United States of America
	Published	Korea, Republic of (KR)
	Registered	European Union International Singapore Taiwan
Insepra	Allowed	United States of America
	Registered	China European Union International Japan Korea, Republic of (KR)

Insepra	Registered	Singapore Taiwan
INSTAVISION	Registered	China International Korea, Republic of (KR) Singapore Taiwan United States of America
INTEGRATED MATERIALS SOLUTION	Application Registered	Korea, Republic of (KR) International Japan United States of America
Intenza	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
INVIA	Application Registered	China Japan European Union Korea, Republic of (KR) Taiwan United Kingdom United States of America
IONIQ	Application Registered	Singapore China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
IRIS	Application	United States of America European Union

IRIS	Application	Japan Korea, Republic of (KR)
	Registered	International Singapore United States of America
ISANI	Registered	United States of America
ISCAN	Registered	United States of America
ISYSTEM	Application	European Union
	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
iSystem Foresight	Registered	Canada European Union International Israel Japan Korea, Republic of (KR) Malaysia Singapore Switzerland United States of America
Javelin	Allowed	Taiwan
	Application	Japan Korea, Republic of (KR) United States of America
	Registered	China European Union International Singapore
KEYSTONE	Registered	China European Union International Japan Korea, Republic of (KR) Singapore

KEYSTONE	Registered	Taiwan United States of America
KINEX	Application	Korea, Republic of (KR) Singapore
	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
KODIAK	Registered	International Korea, Republic of (KR) Taiwan United States of America
LAVACOAT	Registered	United States of America
LDS	Allowed	United States of America
	Application	China Korea, Republic of (KR) Taiwan
	Registered	European Union International Japan Singapore
LEAD	Registered	China European Union India International Japan Korea, Republic of (KR) Taiwan United Kingdom
Lenus	Application	United States of America
Leopard	Allowed	United States of America
	Application	Japan Korea, Republic of (KR) Taiwan

Leopard	Registered	European Union International
LIMITLESS EDGE	Allowed Registered	United States of America Benelux India International Singapore Sweden Switzerland United Kingdom
LINK	Registered	United States of America
Lion	Allowed Application	United States of America China Korea, Republic of (KR) Taiwan
Lucent	Registered Application	European Union International China European Union Japan Korea, Republic of (KR) Singapore Taiwan
Lynx	Published Registered Allowed Application	United States of America International United States of America China Japan Korea, Republic of (KR) Taiwan
Magnus	Registered Allowed Application Published	European Union International Singapore Taiwan European Union Korea, Republic of (KR) Israel Singapore

Magnus	Published Registered	United States of America China International Japan
MAKE POSSIBLE	Registered	European Union Japan Korea, Republic of (KR) Malaysia Singapore United Kingdom United States of America
MARANGONI	Registered	Austria Benelux China France Germany (Federal Republic of) International Italy Japan Liechtenstein Monaco Portugal Spain Switzerland
MARATHON MAX OLED	Registered Application	Korea, Republic of (KR) European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
MDLx	Registered	Canada China European Union International Israel

MDLx	Registered	Japan Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom United States of America
Mecatronics	Registered	Germany (Federal Republic of)
Medeor	Allowed	Taiwan United States of America
	Application	China Japan Korea, Republic of (KR) Malaysia
	Registered	European Union International Singapore United Kingdom
MesoVision	Application	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
MIRRA	Registered	China European Union Hong Kong India Indonesia Israel Japan Korea, Republic of (KR) Singapore Taiwan

MIRRA	Registered	United Kingdom United States of America
MIRRA (and Design)	Registered	European Union United Kingdom
MIRRA MESA	Registered	Korea, Republic of (KR) United States of America
ModuleTwin	Application Registered	Korea, Republic of (KR) European Union International Japan
Momentum Fund	Allowed Application	United States of America Canada China India Japan Korea, Republic of (KR) Malaysia Philippines
	Published Registered	Israel European Union International Singapore Taiwan
monitorMV	Registered	United Kingdom
monitorMV (and Design)	Registered	United Kingdom
Morpher	Allowed Registered	United States of America European Union International Japan Korea, Republic of (KR) Singapore Taiwan
MUSTANG	Registered	United States of America
NEMA	Application Registered	China European Union Japan United States of America

NEOX	Registered	United States of America
NEPTUNE	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom
Net Zero 2040 Playbook	Application	United States of America China European Union India Israel Japan Korea, Republic of (KR) Singapore Taiwan
NetConnect	Registered Allowed Application	United States of America International United States of America China Israel Japan Korea, Republic of (KR) Taiwan
NEW ARISTO	Registered	European Union International Singapore China European Union Germany (Federal Republic of) Japan Korea, Republic of (KR) Taiwan
NEW ARISTO (in Chinese characters)	Registered	United Kingdom China
NEXUS-E	Registered	China European Union

NEXUS-E	Registered	Germany (Federal Republic of) India Indonesia International Japan Korea, Republic of (KR) United Kingdom United States of America
NOKOTA	Registered	United States of America
NutriAPC	Registered	United Kingdom
NutriMV	Registered	China International Singapore United Kingdom United States of America
OLYMPIA	Registered	European Union International Taiwan United Kingdom United States of America
ONYX	Registered	United States of America
OPTA	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
OPTIKON	Registered	United Kingdom
OPTIVA	Registered	United States of America
OPTOPLEX	Registered	Benelux China France Germany (Federal Republic of) International Italy Switzerland

OPTOPLEX	Registered	Taiwan United Kingdom
Palisade	Allowed Application Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
PALOMAR	Registered	United Kingdom
PAT-NAV Pat-Nav PatNav Pat Nav PAT NAV	Registered	United Kingdom
PERCEPTIVE ENGINEERING	Registered	Singapore United Kingdom
Perceptive Engineering	Registered	United Kingdom
PerceptiveAPC	Registered	China International Singapore United Kingdom United States of America
PerformAPC	Registered	United Kingdom
PerformMV	Registered	United Kingdom
PharmaAPC	Registered	United Kingdom
PharmaMV	Registered	China International Singapore United Kingdom United States of America
PharmaNeuron	Registered	United Kingdom
PharmaVision	Application	United States of America
PicoMEDICAL	Registered	Australia Canada India International Israel Japan Korea, Republic of (KR) Russian Federation

PicoMEDICAL	Registered	Singapore Switzerland United States of America
PICOSUN	Registered	Australia Brazil Canada China European Union Finland International Japan Korea, Republic of (KR) Russian Federation Singapore Switzerland United Kingdom United States of America
PICOSUN (in Katakana characters)	Registered	Japan
PICOSUN (in Korean characters)	Registered	Korea, Republic of (KR)
PIKA	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
PIONEER	Application Registered	Japan China European Union International Israel Korea, Republic of (KR) Malaysia Singapore Switzerland Taiwan United Kingdom

PIONEER	Registered	United States of America
PIVOT	Registered	China Germany (Federal Republic of) International Japan Korea, Republic of (KR) Taiwan
PiVot “樞紐” (Chinese translation of the meaning of PiVot)	Registered	Taiwan
PiVot ”樞紐” (Chinese translation of the meaning of PiVot)	Registered	China
Pixel Blending	Registered	European Union International Taiwan
POLARIS	Application Registered	Japan European Union International Israel Korea, Republic of (KR) Singapore Taiwan United States of America
PRECISION	Application Registered	China China International Japan Taiwan
PRECISION 5000	Registered	United States of America Benelux France Hong Kong Indonesia Ireland (Republic of) Israel Italy Singapore Spain Switzerland Taiwan United States of America

PRECISION CVD	Registered	China
Premus	Application	China
		European Union
		Japan
		Korea, Republic of (KR)
		Singapore
		Taiwan
	Published	United States of America
	Registered	International
PRESIDIO	Registered	Canada
		China
		European Union
		International
		Israel
		Japan
		Korea, Republic of (KR)
		Singapore
		Switzerland
		Taiwan
		United Kingdom
		United States of America
PRESTO	Registered	China
PRIME	Registered	International
		Singapore
PRIMEVISION	Registered	China
		European Union
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
		United Kingdom
		United States of America
PRISTINE	Registered	China
		International
		Japan
		Korea, Republic of (KR)
		Taiwan
		United States of America

PRIZM	Registered	United States of America
PROAnalytics	Application	China Japan Korea, Republic of (KR) United States of America
	Registered	International
ProcessTwin	Application	Singapore Korea, Republic of (KR) United States of America
	Registered	European Union International Japan Singapore
PRODUCER	Registered	European Union Japan Taiwan United Kingdom United States of America
PRODUCER KODIAK	Registered	China
PRODUCER NANOCURE	Registered	China
PRODUCER ONYX	Registered	China Japan Korea, Republic of (KR) Taiwan United States of America
PRODUCER XP PRECISION	Registered	China Korea, Republic of (KR)
PROMIS	Registered	United States of America
PROMOTO	Registered	International Korea, Republic of (KR) Taiwan United States of America
Pronto	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America

PROVISION	Registered	China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
pSynapse	Registered	United Kingdom
PURITY	Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
PYRA	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
QbDD	Registered	United Kingdom
QUICKSTART	Registered	China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
RADIANCE	Application Registered	European Union China European Union International

RADIANCE	Registered	Japan Switzerland United Kingdom United States of America
RADION	Published	China
RAIDER	Registered	United States of America
RAIDER	Registered	European Union United Kingdom United States of America
RAPTOR	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
REFLEXION	Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
RETICLEAN	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
RETIGUARD	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan

RETIGUARD	Registered	United Kingdom United States of America
Reveal	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
ROSSA	Registered	China International Japan Korea, Republic of (KR) Taiwan
RT Manager	Registered	International Singapore United Kingdom United States of America
SACVD	Registered	Japan United States of America
SAFARI	Registered	European Union International Korea, Republic of (KR) Singapore Taiwan
Sana	Allowed Registered	United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SANSA	Application Registered	Korea, Republic of (KR) Taiwan China Korea, Republic of (KR) United States of America
SAPHIRA	Application	Malaysia

SAPHIRA	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
SCULPTA	Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
SELECTRA	Application Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom United States of America
SELFI	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
SemiGuru	Allowed Application	Israel Japan Korea, Republic of (KR) United States of America
	Registered	European Union International

SemiGuru	Registered	Singapore Taiwan
SEMITOOL	Registered	Benelux Canada China European Union Ireland (Republic of) Japan Korea, Republic of (KR) Singapore United Kingdom United States of America
SEMVision	Registered	China European Union International Israel Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
SICONI	Registered	United States of America
SideView	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore United States of America
SIGMAMELTEC (Word)	Registered	Japan
SIGNET	Allowed Application	United States of America Canada Switzerland
	Registered	China European Union International Israel

SIGNET	Registered	Japan Korea, Republic of (KR) Malaysia Singapore Taiwan
SILENA	Registered	China European Union International Israel Korea, Republic of (KR) Malaysia Singapore Taiwan United Kingdom United States of America
SILVIA	Registered	United States of America
SINGEN & DESIGN	Registered	United States of America
SIP ENCORE	Registered	United States of America
SIXTHSENSE	Application	Korea, Republic of (KR) Taiwan
	Registered	China Korea, Republic of (KR) United States of America
SLD	Allowed	United States of America
	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SMARTFACTORY	Registered	United States of America
SMARTFACTORY RX	Registered	European Union International Japan Singapore United Kingdom United States of America
SMARTSCHED	Registered	United States of America
SMARTSTART	Published	United States of America Japan

SMARTSTART	Registered	Korea, Republic of (KR) United States of America
SmartWeb	Registered	Benelux China France Germany (Federal Republic of) International Italy Japan Korea, Republic of (KR) Taiwan United Kingdom
SOFT LINE (in Chinese characters)	Registered	European Union
SOFT LINE (Latin characters)	Registered	China
SOLION	Registered	China Japan Taiwan United States of America
SONETTO	Registered	China
SPC3D	Registered	European Union International Japan Singapore United States of America
Sprinter	Allowed Application Registered	United States of America United States of America Japan European Union International Korea, Republic of (KR) Singapore Taiwan
STARK	Application Registered	China International Korea, Republic of (KR) Taiwan
STATIONWORKS	Registered	United States of America
STELLA	Registered	European Union International

STELLA	Registered	Korea, Republic of (KR) Singapore Taiwan
STENSAR	Allowed Registered	United States of America United States of America China European Union International Japan Korea, Republic of (KR) Singapore Taiwan
SuperScan	Registered	European Union International Japan Korea, Republic of (KR) Singapore United States of America
SYM3	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Sym3 Y Magnum	Allowed Application Published Registered Registered	Taiwan United States of America China European Union Israel Japan Korea, Republic of (KR) Singapore International China Japan Korea, Republic of (KR)
SYM3D		China Japan Korea, Republic of (KR)

SYM3D	Registered	Taiwan United States of America
SYNEXIS	Registered	United Kingdom
TANGO	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
	Registered	China European Union Singapore United States of America
TANGO SYSTEMS	Application	International Japan Korea, Republic of (KR) Malaysia Taiwan
	Published	United States of America
	Registered	China European Union Singapore
TARGA	Registered	China International Korea, Republic of (KR) Taiwan United States of America
Technology & Value SIGMAMELTEC (and Design)	Registered	Japan
Technology Enabled Services	Application	China
	Registered	International Japan United States of America
TEMPO	Registered	China European Union Taiwan United Kingdom
TERSA	Registered	China European Union International

TERSA	Registered	Korea, Republic of (KR) Taiwan United Kingdom United States of America
Tesseract	Registered	International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
TETRA	Registered	China European Union International Japan Singapore Taiwan United States of America
THERMION	Registered	China International Korea, Republic of (KR) United States of America
THINK SILICON	Registered	United States of America
Tiburon	Allowed Application	United States of America China Japan Singapore Taiwan
	Registered	European Union International Korea, Republic of (KR) United States of America
TKM	Registered	Taiwan
TKM TOTAL KIT MANAGEMENT	Registered	
ToolTwin	Application	Korea, Republic of (KR) United States of America
	Registered	European Union International Japan Singapore

TOPAZ	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
TOPBEAM	Registered	Benelux China France Germany (Federal Republic of) International Italy Japan Spain United Kingdom United States of America
TOPCOIL	Registered	China Italy Japan Korea, Republic of (KR) Latvia Taiwan
TopMet	Registered	China Germany (Federal Republic of) International Italy Spain United Kingdom
TOTAL KIT MANAGEMENT	Registered	United States of America
TotalConnect	Allowed	United States of America
	Registered	European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan
TreatMag	Registered	Germany (Federal Republic of)

TRIDENT	Registered	Taiwan
TRILLIUM	Registered	Korea, Republic of (KR) Taiwan United States of America
Tripoli	Application Registered	China European Union International Japan Korea, Republic of (KR) Singapore Taiwan United States of America
TrueTarget	Application Published Registered	Israel Korea, Republic of (KR) China European Union International Japan Singapore Taiwan United States of America
TruFilm	Registered	United Kingdom
TruShape	Allowed Application Registered	United States of America International China European Union Japan Korea, Republic of (KR) Singapore Taiwan United Kingdom
TWIN CHAMBER	Registered	United States of America
Twin-AF-Mag	Registered	Benelux China Czechia Finland France Hungary

Twin-AF-Mag	Registered	International Italy Japan Korea, Republic of (KR) Liechtenstein Poland Portugal Spain Sweden Switzerland Taiwan Turkey United Kingdom
TXZ	Registered	Korea, Republic of (KR) United States of America
ULTIMA HDP CVD	Registered	Japan Korea, Republic of (KR) United States of America
UniConnect	Allowed Application	United States of America Japan Korea, Republic of (KR)
	Registered	China European Union International Israel Singapore Taiwan
UVISION	Registered	United States of America
VALAYA	Allowed Registered	United States of America Benelux India International Singapore Sweden Switzerland United Kingdom
Valaya Design Mark	Allowed Registered	United States of America Benelux

Valaya Design Mark	Registered	India International Singapore Sweden Switzerland United Kingdom
VALAYA LIMITLESS EDGE (and Design)	Allowed Published Registered	United States of America India Benelux International Singapore Sweden Switzerland United Kingdom
VANTAGE	Registered	United States of America
VANTAGE RADIANCE	Registered	China Korea, Republic of (KR) Taiwan
VANTAGE VULCAN	Registered	China International Japan Korea, Republic of (KR) Taiwan
VARIAN	Registered	United States of America China
VARIAN CONTROL SYSTEM	Registered	United States of America
VARIAN POSITIONING SYSTEM	Registered	United States of America
VCS	Registered	China
VECTRA IMP SOURCE	Registered	United States of America
VENTARA	Registered	China International Japan Korea, Republic of (KR) Taiwan
VERA	Application Registered	United States of America Japan China European Union

VERA	Registered	International Israel Taiwan United States of America
Veranome Biosystems	Registered	United Kingdom
VERICELL	Registered	United States of America
Veridian	Allowed	Taiwan United States of America
	Application	Japan Korea, Republic of (KR)
	Registered	China European Union International Singapore
VERITYSEM	Registered	United States of America
VERSITA	Allowed	United States of America
	Application	China
	Registered	European Union International Japan Korea, Republic of (KR) Singapore Taiwan
VIISION	Registered	European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
VIISTA	Registered	China European Union Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
Vistara	Registered	China European Union

Vistara	Registered	International Japan Korea, Republic of (KR) Taiwan United States of America
VITA	Registered	China European Union International Israel Japan Korea, Republic of (KR) Singapore Taiwan United States of America
VIVA	Registered	China European Union International Japan Korea, Republic of (KR) Taiwan United Kingdom United States of America
vMask	Registered	United States of America
VOLARIS	Registered	China International Japan Korea, Republic of (KR) Taiwan United States of America
VOLO FLOOD	Registered	China Taiwan
VOLO NEST	Registered	China Taiwan
VOLO PRINT	Registered	China Taiwan
VOLTA	Registered	China International Japan

VOLTA	Registered	Korea, Republic of (KR) Taiwan United States of America
VSEA	Registered	China
WaterAPC	Registered	United Kingdom
WaterMV	Registered	China International Singapore United Kingdom United States of America
WaterNeuron	Registered	United Kingdom
WIZER	Registered	United States of America
WORKSTREAM	Registered	China European Union International Japan United Kingdom United States of America
Xact	Allowed Application	United States of America China Korea, Republic of (KR)
	Published Registered	Singapore International Israel Japan Taiwan
Xsite	Application	Japan Korea, Republic of (KR)
	Registered	European Union International Singapore Taiwan United Kingdom United States of America
ZEPHYR	Registered	United States of America
各美讲堂 - Individual Beauty	Registered	China
應用材料.tw	Registered	Taiwan

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